



Communication Developing an Interferogram-Based Module with Machine Learning for Maintaining Leveling of Glass Substrates

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Abstract: In this research, we propose a method that utilizes machine learning to maintain the parallelism of the resonant cavity in a Fabry–Perot interferometer designed specifically for glass substrates. Based on the optical principle and theory, we establish a proportional relationship between interference fringes and the inclination angle of the mirrors. This enables an accurate determination of the inclination angle using supervised learning, specifically classification. By training a machine learning model with labeled data, interference fringe patterns are categorized into three levels, with approximately 100 training data available for each level in each location. The experimental results of Level 2 and Level 3 classification indicate an average number of corrections of 2.55 and 3.55 times, respectively, in achieving the target position with a correction error of less than 30 arc seconds. These findings demonstrate the essential nature of this parallelism maintenance technology for the semiconductor industry and precision mechanical engineering.

Keywords: Fabry-Perot interferometer; machine learning; auto-leveling; fringe pattern



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1. Introduction

The optoelectronics industry is constantly evolving, demanding increased precision in product accuracy. Precise positioning is crucial, especially in the production of μ LEDs, where light-emitting components have shrunk to micrometer size [1–4]. Matrix transfer technology is necessary for precise μ LED positioning, presenting challenges for both linear and angle positioning. Multidimensional precision positioning is essential for the advancement of high-tech industries. In the past, precision positioning systems used optical scales or encoders as feedback signals, and interferometers were used for error correction. While this method does improve accuracy, it is limited by the optical scales' capabilities and the assembly abilities of the mechanism, making it unsuitable for today's rapidly developing precision manufacturing industry.

The increasing demand for components in the optoelectronics industry, along with the decreasing size of these components, places a significant emphasis on the precision of transfer technology. Various methods have been developed to enhance parallelism detection in order to meet the standard for parallelism during transfer. Figure 1 illustrates a contact-based transfer module, where the adjustment mechanism is triggered by a sensor to level the working module upon contact with the μ LED, as depicted in Figure 1a [3]. Once the sensor of the working module establishes contact with the μ LED on average, the transfer of the μ LED can occur, as shown in Figure 1b. However, the contact-based nature of this detection method is susceptible to causing damage to the μ LED.

Figure 2 illustrates a noncontact detection method in which two sensors (such as laser interferometers or laser displacement sensors) are utilized to determine the angle of the panel. Equation (1) represents the formula for this method, with "l" representing the distance between the two sensors, "h" denoting the measurement deviation between the two sensors, and " θ " indicating the tilt angle of the panel. The distance "l" is a crucial

parameter to the measurement resolution of the tilt angle " θ ". The target panel is a thin glass plate, so the deformation is different in each location. When the sensing spots are located in the working area, the resolution of the tilt angle is rough, as depicted in Figure 2a. If we want to enhance the resolution, the sensing spots will stay away from the working area, as demonstrated in Figure 2b. It means we need to tradeoff between the resolution and the position certainty.

$$\tan \theta = \frac{h}{l} \tag{1}$$

As a solution to achieve a noncontact method and precise parallel positioning, an improved active leveling retention system is imperative to meet the requirements of the industry. This study strives to develop a leveling retention mechanism for glass substrates that integrates machine learning with Fabry–Perot interferometry. By taking into account the optical structure, machine learning control, and feedback, the system enhances the current industry technologies for precise parallelism correction. By employing machine learning for training based on the interference image, this research successfully tackles the accuracy and sensitivity issues associated with traditional methods.



Figure 1. Existing method with contact sensor: (**a**) Tilt angle between panel and working module; (**b**) Without tilt angle.



Figure 2. Existing method with noncontact sensor: (a) The sensing area overlaps with the working area; (b) The sensing area is misaligned with the working area.

2. Materials and Methods

2.1. Fabry–Perot Interferometer (FPI)

The Fabry–Perot interferometer (FPI) is a precise optical device that uses the principle of interference to analyze and manipulate light. It comprises two parallel plane mirrors forming an optical cavity, as illustrated in Figure 3. The light is directed into the cavity and undergoes multiple reflections between the mirrors, leading to constructive and destructive interference. The interference pattern is observed as a series of bright and dark fringes, which are indicative of the parallelism of the resonant cavity [5]. When the two mirrors in the FPI are more parallel to each other, the interference fringes exhibit better contrast and clarity. The density of interference fringe patterns is related to the divergence angle of the incident light beam. In this study, the incident angle " α " is approximately 0°. Consequently, the variation in the interference fringes allows us to measure and assess the parallelism of the resonant cavity with great accuracy [6]. In the context of Fabry-Perot interferometry, using mirrors with high reflectivity is theoretically preferred to achieve finer fringe patterns [7]. However, since the main objective of this study is to maintain the horizontal angular position of the substrate. The substrate is usually with low reflectivity, such as 10~20% reflectivity. For this reason, the two mirrors with 20% reflectivity are employed as the experiment's optical cavity.



Figure 3. The optical configuration of FPI.

The number of interference fringes can be employed to calculate the angle and displacement of the plane mirrors, thereby enabling the determination of the parallelism of the resonant cavity, as demonstrated in Figure 4. The density of interference fringes is directly proportional to the tilt angle. Equations (2) and (3) can accurately determine the degree of parallelism of the resonant cavity.

$$g = \frac{m\lambda}{2}$$
(2)

$$\theta = tan^{-1} \left(\frac{g}{v}\right) \tag{3}$$

In this study, the measurement of displacements is carried out by detecting the changes in interference patterns generated by the resonant cavities. Based on Figure 4, the distance between the resonant cavities is denoted by "*d*", and the *m*th dark fringe is represented by "*m*". The laser light used in the study has a wavelength of 632.8 nm, indicated by the symbol " λ ". The displacement of the measurement mirror is represented by "*g*", while "H" and "V" denote the sensing range of the CCD, which are 4.845 nm and 3.615 nm, respectively. By multiplying the number of fringes by half the wavelength, the displacement of the measurement mirror "*g*" can be obtained. Dividing the displacement by the sensing range of the CCD allows for the calculation of the " θ ".



Figure 4. The association of angles with fringes: (**a**) The resonant cavity has no tilt angle; (**b**) The resonant cavity has tilt angle (red arrow is the direction of the tilt angle of the resonant cavity).

2.2. Machine Learning

The fundamental principles of machine learning include three main methods: supervised learning, unsupervised learning, and reinforcement learning. Supervised learning utilizes labeled data to train a model for making predictions or classifications [8,9]. Unsupervised learning explores unlabeled data to discover hidden structures and relationships [10]. Reinforcement learning focuses on an agent learning through interactions with an environment to maximize cumulative rewards and make sequential decisions [11].

This research conducted an experiment using supervised learning, specifically the classification algorithm, to develop a forecasting model for gathered interference patterns. Supervised learning entails utilizing a labeled dataset to construct a model capable of recognizing patterns and correlations between input and output information, yielding precise predictions when novel data are acquired. Classification is a form of the algorithm used in supervised learning to assign test data into distinct groups, such as identifying and categorizing specific information in a database to draw conclusions [12,13].

According to recent research studies [14,15], machine learning technologies are widely employed to process interferometric fringes or patterns. Furthermore, specific fields such as optics and biology are incorporating machine learning algorithms into their applications [16,17]. Previously, these applications relied on the manual determination of interferometric fringes or patterns. However, with the advent of machine learning technology, these applications can now be executed efficiently, paving the way for automation possibilities.

In this study, we applied this method to establish a database of interference fringe images. The database of fringe images is categorized into three levels: Level 1, Level 2, and Level 3, as shown in Figure 5. There are about 100 training images in each location. When there is only Level 1 classification, the fringe patterns covered by the blue border are approximately 26.9 arc seconds to 282.9 arc seconds, resulting in lower resolution. To address this resolution issue, we introduced the Level 2 classification. This classification extends eight additional fringe patterns with different inclination angles beyond the Level 1 classification, indicated by the orange border. In this case, the angles of Level 1 patterns range from 26.9 arc seconds to 90.3 arc seconds, while the Level 2 patterns span 90.3 arc seconds to 282.9 arc seconds. The classification approach in Level 3 is similar to Level 2. It further extends eight distinct fringe patterns with varying inclination angles, enclosed by the green border, beyond the Level 2 patterns. The angles of Level 2 patterns range from 90.3 arc seconds to 144.4 arc seconds, while the Level 3 patterns range from 144.4 arc seconds to 282.9 arc seconds, resulting in higher resolution. This classification method involves learning the patterns of each level to identify and predict the inclination position of interference fringes, continuously adjusting the angles to the target position through iterative refinement. The correction magnitudes are constant, which is shown as



follows: Level 1 about is 100 arc seconds, and Level 2 is about 200 arc seconds. Level 3 is about 400 arc seconds.

Figure 5. Classification chart.

The neural network structure of the Inception v3 has gained widespread adoption in the realm of visual perception tasks and image processing applications, owing to its remarkable ability to capture intricate patterns and features, as evidenced by its outstanding performance in several studies [18,19]. In this research, we present a novel approach that leverages the power of Inception v3 to automatically detect interference fringes in images that are generated by FPI. Interference patterns are of utmost importance in various domains, such as precision measurement and sensing, where the precise recognition of these fringes is crucial for obtaining dependable information. In addition to Inception v3, there are other modules available for image recognition, including Inception v4, Xception, Residual Net, and many others [20,21]. These modules have been extensively utilized and validated, each with its own unique architecture and performance advantages. When selecting an image recognition module, consider your specific needs and application scenario to choose the most suitable one.

During the preliminary testing phase of the machine learning algorithm and database, the outcomes have been summarized in Table 1. Out of the 6 testing interferometric patterns, the angular positions were accurately identified. This serves as compelling evidence that both the algorithm and the database meet the specific requirements of this research endeavor.



Table 1. The pre-test result of the algorithm and database (angular position and weighting).

3. Development of Proposed Optical Mechanism

This study proposed an optical mechanism based on an FPI, as illustrated in Figure 6. A laser light source is first collimated and then directed toward the pair of primary interferometer mirrors. The interference pattern is obtained by the CCD. To improve the performance of the interferometer, the two stepping motors with adjustable angles were integrated at the rear of the measurement mirror, as shown in Figure 7. This allowed for the automatic correction of any deviations from perfect parallelism in the resonant cavity. After establishing the offset angle, the motors can be governed to fine-tune the pitch and yaw angles, ensuring accurate and stable interferometric measurements.



Figure 6. Proposed optical mechanism.





In this study, the experimental procedure involves several steps to detect changes in the parallelism of the resonant cavity. First, the current interference image is obtained, and then a machine learning-based detection mechanism is used to identify any shift in the parallelism. This mechanism accurately classifies the interference image and converts the recognition result into an angle that indicates the degree of shift. Once the angle is determined, the stepper motor is controlled to adjust the parallelism accordingly. After the adjustment is made, the interference image is obtained again to confirm that the parallelism has been restored. The entire experimental procedure is illustrated in Figure 8, which shows the steps involved in detecting and correcting any shift in the parallelism of the resonant cavity and ensure accurate measurements in various scientific and engineering applications.



Figure 8. Flowchart of the proposed system.

4. Experiment Result and Discussion

In this study, various experiments were conducted using Level 1, Level 2, and Level 3 classifications to identify and correct any shift in the parallelism of the resonant cavity. The experiments involved randomly adjusting the resonance cavity angle and using a machine learning algorithm to determine the type of interference fringe patterns. The stepping motors were regulated to rectify the angular deviation, and the corrective procedure was iterated until the determined outcome reached the target position. Figures 9–12 show the experimental results for the Level 1, Level 2, and Level 3 classifications.



Figure 9. Correction times in Level 2 classification.



Figure 10. Angular deviation of Level 2 classification.



Figure 11. Correction times in Level 3 classification.



Figure 12. Angular deviation of Level 3 classification.

The outcome of the Level 1 classification demonstrates that the segmentation of angular deviations is inadequate. The correction step of each segmentation is pre-determined, and if it is set too small, it will require numerous correction steps to reach the target angular position. Conversely, if the correction step is excessively large, it will fail to converge to a stable target angular position. Consequently, the results of the Level 1 classification experiment are not included in the following discussion.

Table 2 presents the experimental results for the Level 2 classification showing that, on average, 2.55 adjustment times were adequate to re-establish the parallelism of the resonant cavity, as illustrated in Figure 9. The average parallelism error was 41.18 arc seconds, as shown in Figure 10. Additionally, the post-correction error demonstrated a standard deviation of approximately 12.43 arc seconds. These results demonstrate the effectiveness of the proposed method in accurately detecting and correcting any shift in the parallelism of the resonant cavity, which can help improve the accuracy and stability of various scientific and engineering applications that rely on precise measurements.

Number of Experiments	Number of Corrections	Angular Deviation (Arc Second)
1	2	27
2	2	40.5
3	3	54
4	3	40.5
5	2	27
6	1	40.5
7	2	40.5
8	2	27
9	3	54
10	3	40.5
11	2	54
12	4	67.5
13	2	13.5
14	3	40.5
15	3	54
16	3	40.5
17	5	27
18	1	54
19	1	40.5
20	4	40.5

Table 2. Experiment results of Level 2 classification.

The results of the experiment for the Level 3 classification are presented in Table 3. According to the experimental data, the resonator cavity's parallelism could be adjusted with an average of 3.55 corrections (as shown in Figure 11). The average angle deviation was found to be 25.65 arc seconds, as illustrated in Figure 12. After applying corrections, the standard deviation of the error was reduced to approximately 9.45 arc seconds.

Number of Experiments	Correction Times	Angle Deviation (Arc Second)
1	4	27
2	2	13.5
3	5	27
4	6	40.5
5	3	27
6	3	40.5
7	5	27
8	3	13.5
9	3	27
10	2	27
11	3	13.5
12	3	27
13	3	27
14	3	13.5
15	3	40.5
16	4	13.5
17	5	13.5
18	5	27
19	3	27
20	3	40.5

Table 3. Experiment results of Level 3 classification.

It is important to note that the resonator cavity's parallelism plays a crucial role in its performance. Therefore, the small standard deviation of the error suggests that the proposed method is highly effective in correcting the parallelism of the resonator cavity. These results demonstrate the feasibility and reliability of our experimental setup for Level 3 classification. This method can be applied to various resonator cavity systems, making it a versatile and useful tool for researchers and engineers in the field of photonics.

The concept's application is illustrated in Figure 13. Maintaining the posture between the target substrate and the working module is a critical issue in precision mechanical engineering and the semiconductor industry during the manufacturing process. The guiding system's tolerance of the positioning stage causes each target position to have a specific angular posture, which increases the product's defective rate. The proposed system is designed to maintain the angular posture, particularly in positioning applications. The experimental results demonstrate the high potential of this method in posture maintenance for these industries.





5. Conclusions

In order to ensure glass substrate leveling maintenance, this experiment has developed a method that combines machine learning algorithms and sensing technologies. This method is designed to accurately detect and maintain the flatness of glass substrates during various manufacturing processes, ensuring that the final products meet the highest standards of quality and precision. The method proposed in this study not only mitigates the risk of damage from contact with µLED but also effectively addresses the challenge of limited resolution caused by sensor distance. This study utilizes machine learning to improve the precision of an interferometer system, achieving a resolution of 13.5 arc seconds. The experimental results show that the system can restore parallelism with an average correction error of 41.18 arc seconds and a standard deviation of approximately 12.43 arc seconds after about three corrections in the Level 2 classification experiment. In the Level 3 classification experiment, the system can restore parallelism with an average correction error of 25.65 arc seconds and a standard deviation of approximately 9.45 arc seconds after about four corrections. These findings demonstrate the potential of the proposed optical mechanism in enhancing precision mechanical engineering and semiconductor industries.

To further improve the system, advanced imaging software and control systems will be integrated, and the data classifications will be expanded to create a more comprehensive calibration system. This will enable the system to better meet the increasingly demanding requirements of these industries.

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